


U.S. PRO  
U. 996676  
11/30/6

ISSUE C	
Class	Year

STATE OF NEW YORK

U.S. **UTILITY** Patent Application

<p>  </p> <p> O.I.P.E. </p> <p> SCANNED <u>LM3</u> Q.A. <u>VRE</u> </p>	<p> PATENT DATE </p>
--	----------------------

APPLICATION NO.	CONT/PRIOR	CLASS	SUBCLASS	ART UNIT	EXAMINER
09/996676	F	430		1752	

## APPLICANTS

Hideo Hada  
Satoshi Fujimura  
Kazuhito Sasaki  
Takeshi Iwai

Positive-working photoresist composition.

**TITLE**

PTO-2040  
12/99

ISSUING CLASSIFICATION									
ORIGINAL			CROSS REFERENCE(S)						
CLASS		SUBCLASS	CLASS	SUBCLASS (ONE SUBCLASS PER BLOCK)					
430			430	905	914				
INTERNATIONAL CLASSIFICATION									
6	03	F	1	004					

☐ Continued on Issue Slip Inside File Jacket

NOT AVAILABLE COPY

<input type="checkbox"/> <b>TERMINAL DISCLAIMER</b>	<b>DRAWINGS</b>			<b>CLAIMS ALLOWED</b>	
	Sheets Drwg. _____	Figs. Drwg. _____	Print Fig. _____	Total Claims _____	Print Claim for O.G. _____
<input type="checkbox"/> The term of this patent subsequent to _____ (date) has been disclaimed.  <input type="checkbox"/> The term of this patent shall not extend beyond the expiration date of U.S Patent. No. _____  _____ _____	_____ (Assistant Examiner) (Date)			<b>NOTICE OF ALLOWANCE MAILED</b>  _____	
	_____ _____ Rosemary Ashton 2/8/03 (Primary Examiner) (Date)			<b>ISSUE FEE</b>	
				Amount Due	Date Paid
_____ The terminal _____ months of this patent have been disclaimed.	_____ (Legal Instruments Examiner) (Date)			<b>ISSUE BATCH NUMBER</b>	

**WARNING:**

The information disclosed herein may be restricted. Unauthorized disclosure may be prohibited by the United States Code Title 35, Sections 122, 181 and 368. Possession outside the U.S. Patent & Trademark Office is restricted to authorized employees and contractors only.

Form **PTO-436A**  
(Rev. 6/99)

FILED WITH: ☐ DISK (CRF) ☐ FICHE ☐ CD-ROM  
(Attached in pocket on right inside flap)

**BEST AVAILABLE COPY**

(FACE)